

525 U.S. PTO
09/560266
07/26/00

745	Subclass
745	Class
ISSUE CLASSIFICATION	

PATENT NUMBER

U.S. UTILITY Patent Application

O.I.P.E.	PATENT DATE
<i>(B) JR</i>	<i>SB</i>
SCANNED	O.A. ONW

APPLICATION NO. 09/560268	CONT/PRIOR D	CLASS 2-16 43C	SUBCLASS 745	ART UNIT 1746 1765	EXAMINER RKO
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APPLICANTS
Whanghee Lee
Yongjun Hu

TITLE
Method and composition for selectively etching against cobalt silicide

PTO-2040
12/99

ISSUING CLASSIFICATION

ORIGINAL		CROSS REFERENCE(S)			
CLASS	SUBCLASS	CLASS	SUBCLASS (ONE SUBCLASS PER BLOCK)		
43C	745	438	749	750	
INTERNATIONAL CLASSIFICATION		252	791	792	
H01L	21/302				

Continued on Issue Slip Inside File Jacket

TERMINAL DISCLAIMER	DRAWINGS	CLAIMS ALLOWED	
<input type="checkbox"/> The term of this patent subsequent to _____ (date) has been disclaimed.	Sheets Drwg. 61 DUY-YU DEO (Assistant Examiner)	Figs. Drwg. 10 8/2/01 (Date)	Print Fig. 6C (Primary Examiner) (Date)
<input type="checkbox"/> The term of this patent shall not extend beyond the expiration date of U.S. Patent No. _____.	NOTICE OF ALLOWANCE MAILED		
<input type="checkbox"/> The terminal _____ months of this patent have been disclaimed.	ISSUE FEE		
	Amount Due (Legal Instruments Examiner)		Date Paid (Date)
	ISSUE BATCH NUMBER		

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